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GROUP 1700

Docket No.: YOR920000789US1
(PATENT)

1756
5/26/03
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(imc)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Arpan P. Mahorowala

Application No.: 09/902,728

Group Art Unit: 1756

Filed: July 12, 2001

Examiner: Barreca, Nicole M.

For: METHOD TO PREVENT PATTERN
COLLAPSE IN FEATURES ETCHED IN
SULFER DIOXIDE-CONTAINING PLASMAS

REQUEST FOR EXTENSION OF TIME

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Applicant hereby petitions for a one month extension of time to and including June 9, 2003 to respond to the Office Action mailed April 7, 2003.

In the event that a further petition for an extension of time is required to be submitted at this time, applicant hereby petitions under 37 CFR 1.136(a) for an extension of time for as many months as are required to ensure that the above-identified application does not become abandoned.

Please charge our Deposit Account No. 22-0185 in the amount of \$110.00 covering the fee set forth in 37 CFR 1.17(a)(1).

Dated: May 15, 2003
7799_1

05/21/2003 SDENB0B1 00000001 220185 09902728
01 FC:1251 110.00 CH

Respectfully submitted,

By 
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